

UNITED STATES PATENT AND TRADEMARK OFFICE

BEFORE THE PATENT TRIAL AND APPEAL BOARD

ZHUHAI COSMX BATTERY CO., LTD.,
Petitioner,

v.

NINGDE AMPEREX TECHNOLOGY LIMITED,
Patent Owner.

Case No. IPR2023-00585
U.S. Patent No. 11,329,352

**PETITIONER'S POWER OF ATTORNEY AND
DESIGNATION OF LEAD AND BACKUP COUNSEL**

Pursuant to 37 C.F.R. § 42.10(b), Petitioner Zhuhai CosMX Battery Co., Ltd. hereby appoints the practitioners associated with Finnegan, Henderson, Farabow, Garrett & Dunner, LLP, Customer Number 22,852, including the following lead and back-up counsel, as its attorneys to transact all business in the U.S. Patent and Trademark Office associated with the above-captioned *inter partes* review of U.S. Patent No. 11,329,352:

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The individual signing below has the authority to execute this document on
behalf of Petitioner Zhuhai CosMX Battery Co., Ltd.

By: Alex Li

For Zhuhai CosMX Battery Co., Ltd.

Name: Alex Li

Title: Vice president

Date: Mar. 30, 2023